

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L13	8205	(polysilicon or polySi or ((polycrystal\$6 or poly) adj (Si or silicon))) near15 (pattern\$6 or etch\$6 or remov\$6) near15 selectively	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/05/12 12:01
L14	20851	(polysilicon or polySi or ((polycrystal\$6 or poly) adj (Si or silicon))) near15 (implant\$6 or ionimplant\$6)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/05/12 12:01
L15	2519	13 and 14	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/05/12 12:01
L16	860	13 same 14	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/05/12 12:02
L17	821	16 and (@ad<="20031117" or @rlad<="20031117")	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/05/12 12:03
L18	2189	13 same (pad or bit or bitline or plug or contact)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/05/12 12:03
L19	260	17 and 18	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/05/12 12:03